

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Application of

Inventor(s): DHINDSA, Rajinder et al. : Confirmation No.8414

U.S. Patent Application No. 10/645,665 : Group Art Unit: 2821

Filed: August 22, 2003 : Examiner: TUNG X LE

For: MULTIPLE FREQUENCY PLASMA ETCH REACTOR

**INFORMATION DISCLOSURE STATEMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached form PTO-1449.

This Information Disclosure Statement is being filed under Rule 37 CFR 1.97(i), wherein applicants are submitting an IDS before the grant of a patent to be placed in the file but not considered by the Patent Office. No certification or fees are deemed necessary.

Respectfully submitted,

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